Special Issue

Adaptive Control: Design and Analysis

Message from the Guest Editors

The aim of this Special Issue is to explore recent technological developments in adaptive control (design methods and theoretical analysis), especially for nonlinear stochastic processes such as robotic systems, manufacturing systems, transportation systems, power systems, chemical systems, and more. Research areas may include (but are not limited to) the following:

- Model reference adaptive control;
- Self-tuning adaptive control;
- Multiple model adaptive control;
- Intelligent adaptive control;
- Robust adaptive control;
- Adaptive sliding-mode control

Guest Editors

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Deadline for manuscript submissions

closed (31 October 2023)



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